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## ED STATES PATENT AND TRADEMARK OFFICE

Applicant: Haruo Hyodo et al.

Serial No.: 09/963,267

Title

Filed

September 26, 2001

SEMICONDUCTOR DEVICE AND MANUFACTURING METHOD THEREOF

Art Unit

Examiner: Ida W. Soward

Commissioner for Patents Washington, D.C. 20231

## RESPONSE

In response to the action mailed February 19, 2002, please amend the application as follows:

In the claims:

Please amend claim 1 as follows:

-- 1. (Amended) A semiconductor device comprising:

a supporting substrate made of insulating material;

a conductive pattern provided on a surface of the supporting substrate;

an external connecting terminal provided on a back surface of the supporting substrate and electrically connected to the conductive pattern;

a circuit element provided on the conductive pattern;

a glass plate that covers the circuit element and that forms a hollow airtight porten

between the supporting substrate and the glass plate; and

an adhesive resin applied over an entire surface of the glass plate. -

Please add claims 8 to 11.

CERTIFICATE OF MAILING BY FIRST CLASS MAIL

I hereby certify under 37 CFR §1.8(a) that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage on the date indicated below and is addressed to the Commissioner for Patents, Washington, D.C. 20231.

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